

Comparative Analysis of Lithium Doping Effects on Physical Properties of Iron Oxide Thin Films

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Abstract: The impact of Li concentration on certain physical characteristics of Undoped Fe₂O₃ thin films grown by chemical spray pyrolysis (CSP) is examined in this work. Undoped and Li-doped films (2% and 4% Li) were prepared from iron acetate precursor with lithium nitrate as the dopant source. XRD analysis assures a hexagonal (wurtzite) with a prevailing (200) plane. Li incorporation caused a slight peak shift, increased the crystallite size from 18.63 nm to 29.2 nm, and reduced dislocation density and lattice strain, thereby enhancing crystallinity. Atomic force microscopy (AFM) disclosed that average particle size and surface roughness decreased with higher Li doping, recommending grain refinement. Optical transmittance decreased with doping, while the absorption coefficient increased. The bandgap narrowed from 2.58 eV to 2.47 eV with 4% Li, due to presence of defect states. The extinction coefficient decreased, and the refractive index also reduced upon doping. Gas-sensing tests for NO₂ at 150°C displayed that Li doping raised baseline resistance but significantly reduced sensitivity, dropping from 39.53% to 15.95% at 60 ppm.

1 INTRODUCTION

Iron oxide (Fe₂O₃) has emerged as highly promising for different technological uses, like lithium-ion batteries, photocatalytic water splitting, supercapacitors, and gas sensors, due to its environmental stability, and suitable bandgap [1]-[4]. Among its polymorphs, hematite is the most stable phase and has been extensively studied for optoelectronic and sensing devices [5]-[10]. To overcome and enhance the properties, doping with transition-metal and alkali thin films [11]-[13]. Various deposition techniques were employed to prepare Fe₂O₃ thin films, including atomic layer deposition, ion-beam assisted deposition, CVD, and sol-gel methods [14]-[17]. Among these, CSP stands out due to its ability to produce uniform, large-area films with controlled stoichiometry [18]-[20]. CSP allows precise control over precursor concentration, substrate temperature, doping level, and deposition time, making it ideal for systematic property

tuning [21]-[23]. Numerous studies have investigated different fabrication techniques for Fe₂O₃ thin films, including CVD [24], sol-gel methods [25], [26], PLD [27], thermal evaporation [28], DC reactive magnetron sputtering [29], sputtering [30], and chemical spray pyrolysis (CSP) [31]. The present work aims to investigate the impact of Li doping concentration (0%, 2%, and 4%) on Physical characterizations of Fe₂O₃ thin films deposited by CSP.

2 EXPERIMENTAL

0.05 M of (Fe(CH₃COO)₂·2H₂O) was put in 100 mL of deionized water (W_{de}) to create a precursor solution. For doping, a separate solution containing 0.1 M lithium nitrate hydrate (LiNO₃·xH₂O) was prepared in W_{de}. The dopant solution was then added to the precursor to achieve Li concentrations of 2% and 4% by volume. For the deposition process, a

spray system was employed with a nozzle-to-base distance of 30 cm. The spraying duration was maintained at 8 seconds, with an interval of 1.5 minutes between spray cycles. The carrier's gas was compressed air at 10^5 Pa. The thickness of the prepared films was determined by gravimetric method, yielding an average thickness of 340 ± 25 nm. The structural properties were analyzed via XRD. Furthermore, the surface morphology was studied utilizing AFM (AA3000 Scanning Probe Microscope). Additionally, transmittance was computed using a UV-Visible spectrophotometer. The gas-sensing performance was evaluated by measuring changes in electrical resistance within a custom-designed cylindrical test chamber (radius: 8 cm, height: 16 cm) under controlled hydrogen exposure.

3 RESULTS AND DISCUSSION

XRD patterns were analyzed and compared with the standard ICDD card No. 42-1340. Figure 1 presents the diffraction patterns of the films deposit via chemical spray pyrolysis (CSP) technique. All samples exhibit a hexagonal (wurtzite) structure, with a predominant orientation along the (200) plane. Several diffraction peaks were observed at 2θ values of 28.47° , 33.37° , and 64.47° , associated with (111), (200), and (321) planes, respectively. It was also observed that the position of the (200) peak shifts slightly with increasing lithium doping concentration [32]. This shift can be attributed to lattice distortion generated by Li ions being incorporated into the host lattice.

The crystallite size (D) was estimated from the diffraction peak's FWHM (β), the Bragg angle (θ),

and the X-ray wavelength (λ) using the Scherrer equation [33], [34].

The results show that lithium incorporation increases D from 18.63 nm to 29.2 nm. This increase in D is attributable to lithium ions, which enhance crystal growth during film formation [35].

The dislocation density (δ), which is inversely proportional to the square of the crystallite size, was evaluated following [36], [37].

The results indicate that δ declines from 44.74 to 20.74×10^{14} lines/m² with increasing lithium doping, proposing significant reduction in lattice imperfections. This decline in δ is attributable to lithium-induced enhancement of crystallinity [38], [39].

The lattice strain (ϵ) was determined from the diffraction peak broadening and the Bragg angle [40].

The results reveal that the lattice strain (ϵ) decreases from 25.84 to 20.19 with increasing lithium doping, indicating a reduction in internal lattice distortions. This decrease in ϵ can be explained by the crystal lattice's inclusion of lithium ions [41], [42]. Table 1 summarizes the effect of varying lithium doping content on the structural parameters (S_{para}) of Fe₂O₃ thin films.

AFM images were quantitatively analyzed regarding average particle size (P_{av}), average roughness (R_a), and root-mean-square roughness (RMS). Figure 2 shows that the measured values of P_{av} were 82.3, 68.2, and 37.8 nm, while the corresponding R_a values were 6.81, 6.48, and 3.19 nm, and RMS values were 5.78, 4.70, and 4.19 nm, respectively. These results demonstrate a clear dependence of surface morphology on lithium doping concentration. Furthermore, Table 2 indicates that both P_{av} and R_a decrease with increasing lithium content. This reduction is attributable to lithium ions' role in modifying nucleation and growth during film formation [43], [44].

Table 1: Structural parameters and optical band gap of undoped and Li-doped Fe₂O₃ thin films.

Sample	2θ ($^\circ$)	(hkl) Plane	β ($^\circ$)	E_g (eV)	D(nm)	$\delta \times 10^{14}$ (lines/m ²)	$\epsilon (\times 10^{-4})$
Undoped Fe ₂ O ₃	28.47	200	0.61	2.72	18.63	44.74	25.84
Fe ₂ O ₃ : 2 % Li	28.44	200	0.59	2.66	24.98	37.73	21.81
Fe ₂ O ₃ : 4 % Li	28.40	200	0.51	2.60	29.22	20.74	20.19

Table 2: AFM surface morphology parameters of undoped and Li-doped Fe₂O₃ thin films.

Sample	P_{av} (nm)	R_a (nm)	RMS (nm)
Undoped Fe ₂ O ₃	82.3	6.81	7.81
Fe ₂ O ₃ : 2 % Li	68.2	6.48	4.70
Fe ₂ O ₃ : 4 % Li	37.8	3.19	4.19

The transmittance (T) was determined from the ratio of the transmitted light intensity (I) to the incident light intensity (I_0) [45].

Figure 3 presents T spectra; the data indicate a gradual decrease in transmittance with increasing Lithium doping, while transmittance increases with wavelength across the measured range. All films maintain high T within the visible spectrum, with T values varying from 75.5% for Fe_2O_3 to 71.3% for Fe_2O_3 doped with 4% Lithium. This trend can be attributed to Lithium's influence on the film's microstructure. Doping increases grain size and reduces lattice strain, thereby enhancing light scattering and absorption and lowering transmittance [46]-[49].

The absorbance (A) was calculated from the transmittance using the standard logarithmic relation [50].

The absorption spectra of undoped and 4% Lithium-doped Fe_2O_3 thin films, presented in Figure 4, demonstrate a notable increase in absorption with higher Lithium doping [51], [52]. This enhancement is attributable to Lithium content, which modifies the electronic band structure, creates additional defect states, and facilitates greater photon-electron interactions. Consequently, more incident photons are absorbed, particularly in the visible region, reflecting the dopant's impact on the films' optical and electronic properties [53].

The absorption coefficient (α) was evaluated from the transmittance and film thickness (t) [54].

As illustrated in Figure 5, the absorption coefficient rises with higher Lithium content. This trend can be explained by the introduction of Lithium, which generates additional localized states and enhances electronic transitions within the band structure. The probability of photon absorption rises, leading to an overall increase in α with dopant concentration [55], [56].

The direct bandgap (E_g) was determined from the Tauc relation between α and photon energy ($h\nu$), taking $r = 1/2$ for a direct transition [57].

E_g decreased from 2.58 eV for the undoped film to 2.47 eV upon raising Lithium content (Fig. 6). This reduction in E_g is attributable to Lithium content, which introduces additional energy states within the band structure. These localized states facilitate electronic transitions at lower photon energies, effectively narrowing the bandgap. Such bandgap tuning is consistent with the observed increase in α , reflecting enhanced optical activity and a modified electronic structure due to dopant-induced lattice perturbations [58], [59].

The extinction coefficient (k) was evaluated from the absorption coefficient (α) and wavelength (λ) [36].

As shown in Figure 7, k decreases with increasing Lithium doping. This decline indicates reduced absorption losses per unit thickness, which can be associated with the modified electronic structure and the lower conduction band density of states resulting from Lithium incorporation [60].

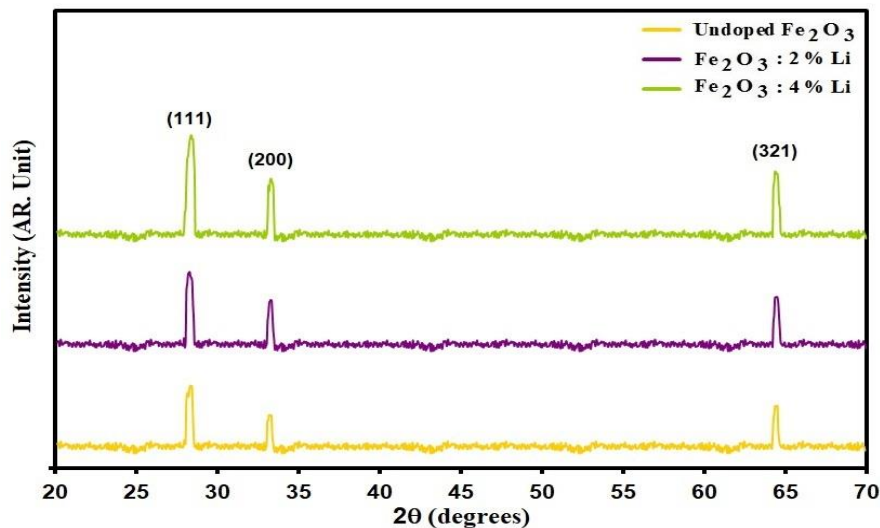


Figure 1: XRD patterns of undoped and Li-doped Fe_2O_3 thin films.

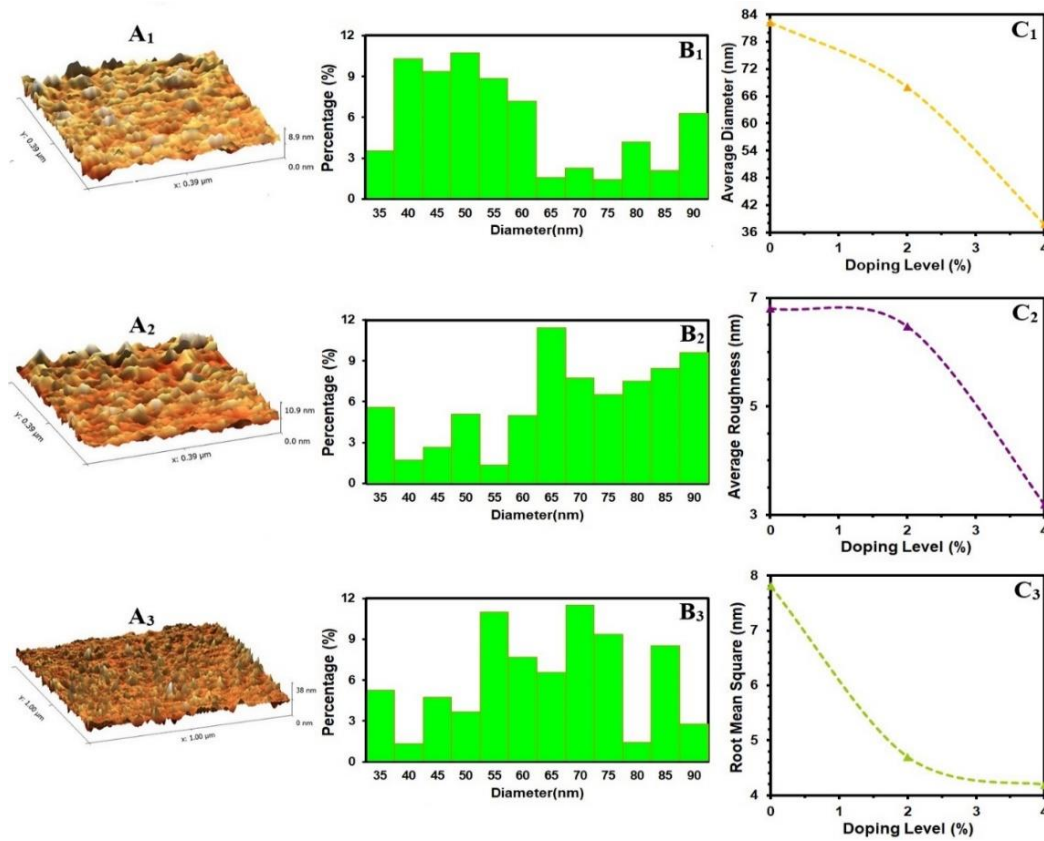


Figure 2: AFM surface images of undoped and Li-doped Fe_2O_3 thin films.

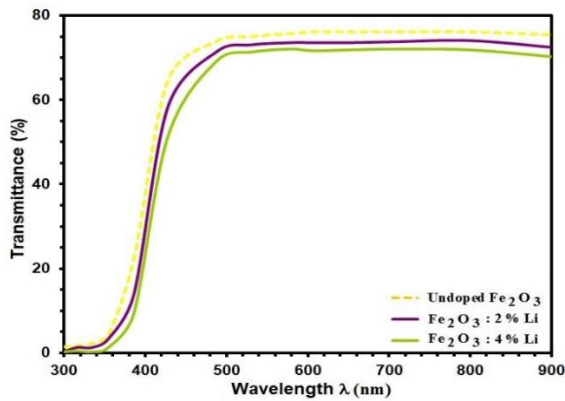


Figure 3: Optical transmittance spectra of undoped and Li-doped Fe_2O_3 thin films.

The refractive index (n) was determined from the reflectance (R) and extinction coefficient (k) [61].

Figure 8 illustrates the wavelength-dependent variation of n for the deposited Fe_2O_3 films. n decreases with increasing Lithium concentration [39]. This reduction is attributable to Li content, which alters the local electronic polarizability and thereby reduces the material's overall density. Consequently,

the interaction of light with the film is weakened, leading to a lower refractive index [62], [63].

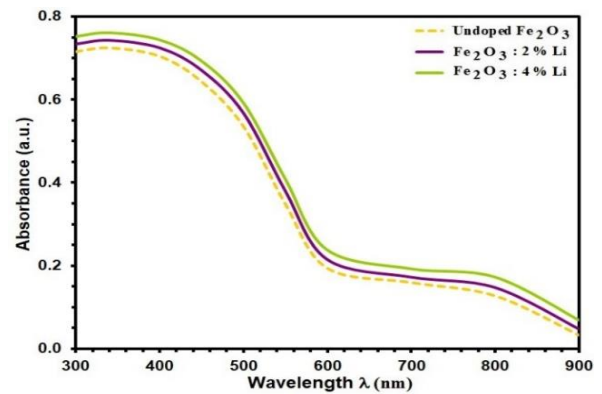


Figure 4: Optical absorbance spectra of undoped and Li-doped Fe_2O_3 thin films.

The gas sensor performance was evaluated at an operating temperature of 150°C . Figure 9 presents the resistance variation of the Fe_2O_3 films upon exposure to NO_2 gas at a concentration of 180 ppm. It was mentioned that undoped Fe_2O_3 films displayed

lowest resistance [64], whereas the 4% Lithium-doped Fe_2O_3 film showed the highest resistance [65]. This behavior can be explained by the effects of Lithium doping on the charge-carrier concentration and mobility: Li incorporation reduces the free-electron density and increases carrier scattering, thereby increasing the baseline resistance.

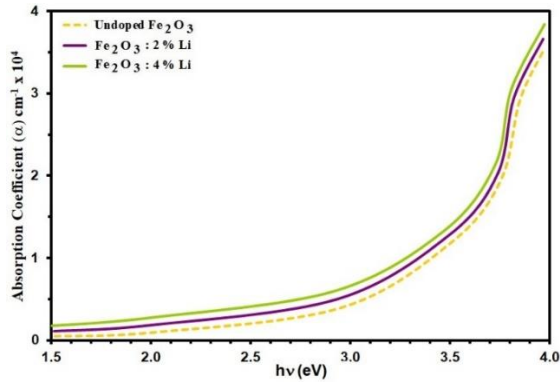


Figure 5: Absorption coefficient (α) spectra of undoped and Li-doped Fe_2O_3 thin films.

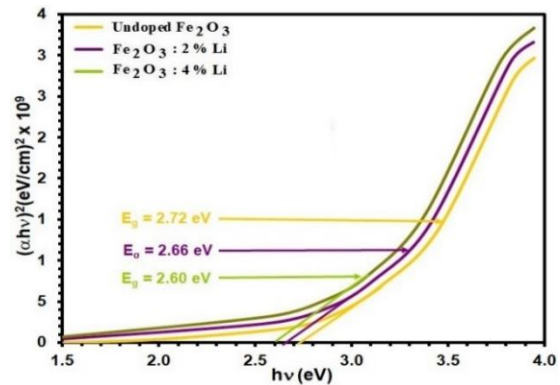


Figure 6: Tauc plots for determining the optical band gap (E_g) of undoped and Li-doped Fe_2O_3 thin films.

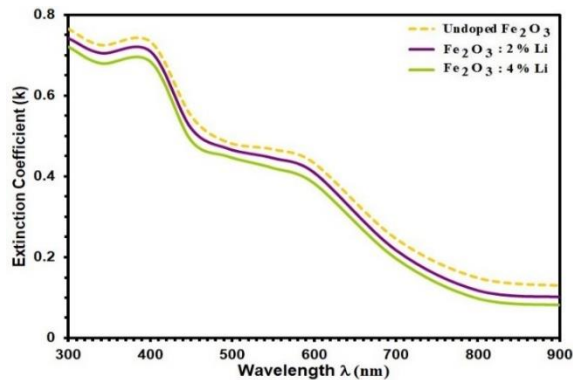


Figure 7: Extinction coefficient (k) spectra of undoped and Li-doped Fe_2O_3 thin films.

The sensitivity (S) of the films toward NO_2 gas was quantified from the relative change in resistance between air and gas exposure [66].

R_a denotes the resistance in the presence of gas and R_g is the film sensor's resistance in air. Figure 10 displays S plots of Fe_2O_3 , Fe_2O_3 :2% Li, and Fe_2O_3 :4% Li films, highlighting the impact of Lithium doping on gas response. The recombination dynamics of charge carriers influence the sensor's sensitivity: as Lithium concentration increases, enhanced carrier scattering and reduced mobility accelerate electron-hole recombination, thereby decreasing the sensor's sensitivity. The sensitivity decreases with increased Li content across all tested NO_2 concentrations [67]-[69]. For Fe_2O_3 , Fe_2O_3 : 2% Li, and Fe_2O_3 : 4% Li films, the sensitivity drops from 39.53% to 15.95% at 60 ppm, from 40.91% to 17.33% at 120 ppm, and from 42.55% to 18.84% at 180 ppm [68]. This trend demonstrates that while Lithium doping can improve structural and optical properties, it simultaneously reduces the effective charge modulation under gas exposure, thereby diminishing gas-sensing performance at higher dopant levels.

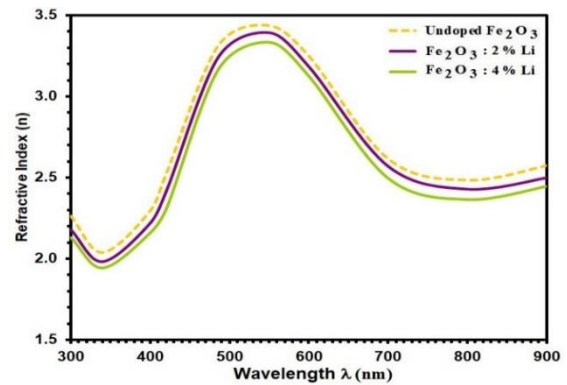


Figure 8: Refractive index (n) spectra of undoped and Li-doped Fe_2O_3 thin films.

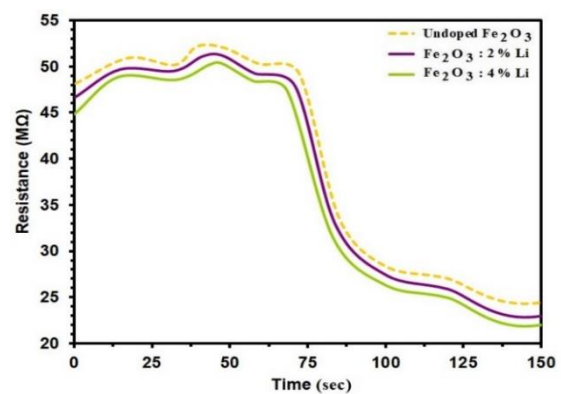


Figure 9: Resistance response of undoped and Li-doped Fe_2O_3 thin films to 180 ppm NO_2 at 150 °C.

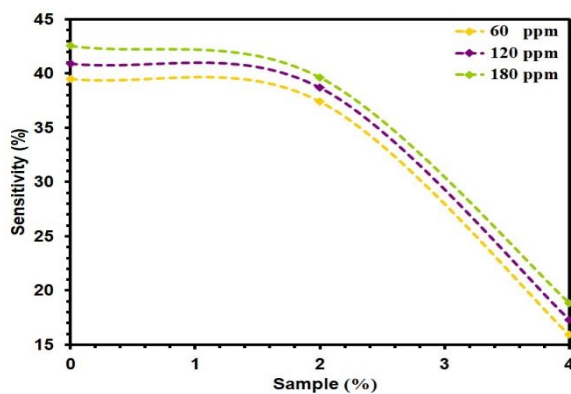


Figure 10: Gas sensitivity of undoped and Li-doped Fe_2O_3 thin films toward NO_2 .

4 CONCLUSIONS

The grown of undoped and Li-doped Fe_2O_3 thin films was successfully demonstrated via CSP. The structural analysis revealed that Li doping enhances crystallinity, as evidenced by increased crystallite size (up to 29.2 nm for 4% Li), decreased dislocation density (from 44.74 to 20.74×10^{14} lines/m²), and reduced lattice strain. These improvements are attributed to Li ions, which facilitate crystal growth and reduce lattice imperfections. Morphologically, AFM showed a decrease in the average particle size (P_{av}) from 82.3 nm to 37.8 nm and a reduction in surface roughness with increasing Li concentration, indicating that Li modifies nucleation and growth kinetics. Optically, Li doping reduced transmittance and the bandgap (from 2.58 to 2.47 eV), while increasing the absorption coefficient, making Li: Fe_2O_3 suitable for visible-light applications. However, the gas sensing performance toward NO_2 at 150°C deteriorated with Li doping. The sensitivity decreased significantly across all tested concentrations (60, 120, and 180 ppm) because Li incorporation reduces the free-electron density and enhances carrier scattering, leading to faster electron-hole recombination and diminished resistance modulation. Therefore, Li-doped Fe_2O_3 thin films exhibit superior structural and optical properties for optoelectronic applications.

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